

Docket No.: 2038-297

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Toshio KOBAYASHI

U.S. Patent Application No.: *not yet assigned*

Filed: *herewith*

For: NONWOVEN FABRIC AND PROCESS FOR MAKING THE SAME

**INFORMATION DISCLOSURE STATEMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

Respectfully submitted,

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**Date: September 22, 2003**  
BJH/etp

INFORMATION DISCLOSURE CITATION IN AN APPLICATION  (PTO-1449)				ATTY. DOCKET NO. 2038-297		U.S. APPLICATION NO. Not yet assigned	
				APPLICANT Toshio KOBAYASHI			
				FILING DATE herewith		GROUP	
U.S. PATENT DOCUMENTS							
EXAMINER'S INITIALS	PATENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE	
FOREIGN PATENT DOCUMENTS							
EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						Yes	No
	4-11021	01/1992	Japan				X
	6-184897	07/1994	Japan				X
	9-291454	11/1997	Japan				X
	9-316748	12/1997	Japan				X
	9-512313	12/1997	Japan				X
	P3262803	12/2001	Japan				X
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)							
EXAMINER				DATE CONSIDERED			

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.